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From : Director, CSIR-National Physical Laboratory No. 14-VII/ST(2819)21/PB/T-103

DATED: 24.12.2021

## CORRIGENDUM

With reference to NPL's Global Tender No. 14-VII/ST(2819)21/PB/T-103 for the procurement of "Inductively Coupled Plasma Mass Spectrometry" Kindly note the following extension in **date** of submission & date of opening of the said tender :-

For : Due date & Time of tender submission Read as : 11.01.2022 up to 03.00 PM (IST)

For : Date & Time of Tender Opening Read as : 12.01.2022 from 3.00 PM (IST) onward

Apart from above, amended Technical specifications (Annexure-I) is also ATTACHED with this Corrigendum. Accordingly, all the interested bidders may submit their Offer as per revised technical specification.

Please also note that bids submitted without taking these changes into consideration will be rejected summarily.

All other terms will remain the same. The same is also available on CSIR-NPL official website http://www.nplindia.org under Tender link.

Sd/-

(Controller of Stores & Purchase)

## Annexure I

## SPECIFICATION FOR INDUCTIVELY COUPLED PLASMA MASS SPECTROMETRY

<u>Sl.No.</u>	Tender Specifications	Amendment in Specifications
1A	A multichannel and ≥10 rollers peristaltic pump which can support variable flow rates, with three separate channels as 1) for sample introduction, 2) for Internal standard, 3) Spray chamber drain.	<ul> <li>A multichannel and ≥10 rollers peristaltic pump which can support variable flow rates, with three or more separate channels as</li> <li>1) for sample introduction,</li> <li>2) for Internal standard,</li> <li>3) Spray chamber drain.</li> </ul>
1C	A factory fitted Peltier cooled, temperature-controlled quartz spray chamber is must with temperature range -5°C to + 20°C or better.	A factory fitted Peltier cooled, temperature-controlled quartz spray chamber with temperature range -5°C to + 20°C or better temperature range
2	RF power source for ICP torch: RF Generator (source): 27 or 34 or 40 MHz frequency, solid state power source and it should be fully computer controlled. Forward power range: 500 - 1500 Watts or better. Plasma shut down: Automatic shutdown of the plasma by the system after completion of analysis.	RF power source for ICP torch: RF Generator (source): 27 or 34 or 40 MHz frequency, solid state power source and it should be fully computer controlled. Forward power range: 400 - 1500 Watts or better. Plasma shut down: Automatic shutdown of the plasma by the system after completion of analysis.
5	Quadrupole mass analyser It should be made of molybdenum or stainless steel or any other suitable material. Mass range should be 2 to 260 amu or better	<u>Quadrupole mass analyser</u> It should be made of molybdenum or stainless steel or any other suitable material. Mass range should be 2 to 260 amu or better range

	Scan speed should be 3000 amu/sec.	Scan speed should be 3000 amu/sec or
	<u>RF generator</u> : frequency should be 2	higher.
	MHz or higher	<u>RF generator</u> : frequency should be 2
	Resolution: computer-controlled	MHz or higher
	settings for quadrupole resolution	Resolution: computer-controlled settings
	should be available	for quadrupole resolution should be
		available
6	Vacuum system: Should have rotary	Vacuum system: Should have rotary
	pump (oil free) and turbo molecular	pump (oil free) and turbo molecular
	pump with split flow for high gas	pump with split flow for high gas
	Through put. Vacuum should be better	Through put. Vacuum should be better
	than 1x10-5 mbar in open valve	than 1x10-5 mbar in open valve
	condition and shall be better than 5 x	condition and shall be better than 5 x
	10-5 mbar in closed valve condition. If	10-5 mbar in closed valve condition. If
	vacuum failure occurs system must be	vacuum failure occurs system must be
	automatically Back filled with	automatically Back filled with
	inert gas to preserve the cleanliness of	inert gas or appropriate facility to lock
	more gas to preserve the creatiness of	ment gas of appropriate facility to lock
	the system.	the vacuum to preserve the cleanliness
7		the vacuum to preserve the cleanliness
7	the system.	the vacuum to preserve the cleanliness of the system.
7	the system. Ion detection with electron multiplier	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier
7	the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic
7	the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog and/or
7	the system. Ion detection with electron multiplier shall ensure $\geq$ 9 orders of linear dynamic range using simultaneous analog/pulse counting. It should be able	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog and/or pulse counting. It should be able to
7	the system. Ion detection with electron multiplier shall ensure $\geq$ 9 orders of linear dynamic range using simultaneous analog/pulse counting. It should be able to measure major and minor	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog and/or pulse counting. It should be able to measure major and minor concentrations
7	the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog/pulse counting. It should be able to measure major and minor concentrations in a single analytical run.	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog and/or pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have
7	the system. Ion detection with electron multiplier shall ensure $\geq$ 9 orders of linear dynamic range using simultaneous analog/pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog and/or pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and fully
7	the system. Ion detection with electron multiplier shall ensure $\geq$ 9 orders of linear dynamic range using simultaneous analog/pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and fully automated detector cross	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog and/or pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and fully automated detector cross calibration
	the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog/pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and fully automated detector cross calibration with good linearity.	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog and/or pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and fully automated detector cross calibration with good linearity.
	the system. Ion detection with electron multiplier shall ensure $\geq$ 9 orders of linear dynamic range using simultaneous analog/pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and fully automated detector cross calibration with good linearity. <u>Gas supply system to ICP-MS system</u>	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog and/or pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and fully automated detector cross calibration with good linearity. <u>Gas supply system to ICP-MS system</u>
	the system. Ion detection with electron multiplier shall ensure $\geq$ 9 orders of linear dynamic range using simultaneous analog/pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and fully automated detector cross calibration with good linearity. <u>Gas supply system to ICP-MS system</u> <u>– 1 Set</u>	the vacuum to preserve the cleanliness of the system. Ion detection with electron multiplier shall ensure $\geq 9$ orders of linear dynamic range using simultaneous analog and/or pulse counting. It should be able to measure major and minor concentrations in a single analytical run. Should have over range protection and fully automated detector cross calibration with good linearity. <u>Gas supply system to ICP-MS system</u> <u>– 1 Set</u>

	flow rates. Such a gas supply system		flow rates. Such a gas supply system
	should include:		should include:
	I. All required gases(Argon - 4		I. All required gases(Argon – 4 nos.;
	nos.; Helium – 2 nos.; Methane		Helium – 2 nos.; <mark>Methane – 1 no,</mark>
	– 1 no./ Oxygen – 1 no.;		Oxygen – 1 no., Hydrogen – 1 no. as
	/Hydrogen – 1 no. as		applicable for Plasma formation,
	applicablefor Plasma formation,		Collision cell and/or Reaction cell
	Collision co	ell	II. Two stage Gas pressure S.S.
	II. Two stage	Gas pressure S.S.	regulators for each cylinder
	regulators f	for each cylinder	III. Gas purification panels for all
	III. Gas purification panels for all		gases.
	gases.		IV. Gas supply automated manifold
	IV. Gas supply	y automated manifold	for switching Argon and He gas
	for switching	ng Argon and He gas	cylinder.
	cylinder.		V. Complete SS tubing's
	V. Complete S	SS tubing's	Complete set of Tool Kit.
	Complete set of Tool Kit.		
12.	Appropriate water recirculation chiller		Appropriate water or coolant
	for ICP MS system	as standard	recirculation chiller for ICP MS system
	accessory from Original Equipment Manufacturer – 1 No.		as standard accessory from Original
			Equipment Manufacturer – 1 No.
13	<u>Auto sampler</u> Capable to run uptoatleast 100 numbers		Auto sampler
			Capable to run at least 100 or more
	of samples with different sample holder		numbers of samples with different
	of capacity 15 ml, 50 ml.Wash/rinse		sample holder of capacity 15 ml, 50
	bottles min 5 nos.at a time		ml.Wash/rinse bottles min 5 nos.at a
			time